



ELECTRONIC COPY

LABORATORY GROWN DIAMOND REPORT

LG651482896
Report verification at igi.org

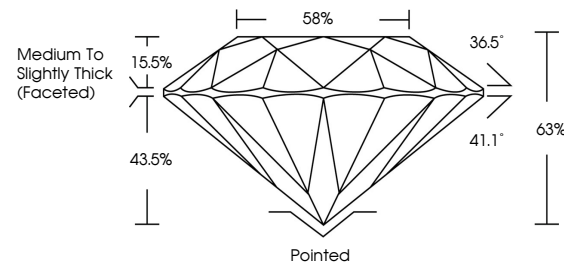
September 30, 2024	
IGI Report Number	LG651482896
Description	LABORATORY GROWN DIAMOND
Shape and Cutting Style	ROUND BRILLIANT
Measurements	7.99 - 8.04 X 5.05 MM
GRADING RESULTS	
Carat Weight	2.01 CARATS
Color Grade	E
Clarity Grade	VS 2
Cut Grade	EXCELLENT

ADDITIONAL GRADING INFORMATION

Polish	EXCELLENT
Symmetry	EXCELLENT
Fluorescence	NONE
Inscription(s)	161 LG651482896

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.
Type IIa

PROPORTIONS



Sample Image Used

COLOR

D E F G H I J Faint Very Light Light

CLARITY

IF	VVS ¹⁻²	VS ¹⁻²	SI ¹⁻²	I ¹⁻³
Internally Flawless	Very Very Slightly Included	Very Slightly Included	Slightly Included	Included

© IGI 2020, International Gemological Institute

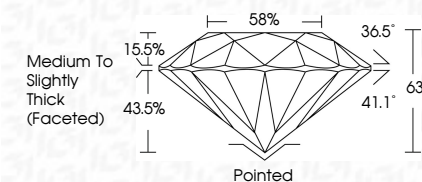
FD - 10 20

www.igi.org

LABORATORY GROWN DIAMOND REPORT



September 30, 2024	
IGI Report Number	LG651482896
Description	LABORATORY GROWN DIAMOND
Shape and Cutting Style	ROUND BRILLIANT
Measurements	7.99 - 8.04 X 5.05 MM
GRADING RESULTS	
Carat Weight	2.01 CARATS
Color Grade	E
Clarity Grade	VS 2
Cut Grade	EXCELLENT



ADDITIONAL GRADING INFORMATION

Polish	EXCELLENT
Symmetry	EXCELLENT
Fluorescence	NONE
Inscription(s)	163 LG651482896
Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.	
Type IIa	



September 30, 2024
IGI Report No LG651482896
ROUND BRILLIANT

7.99 - 8.04 X 5.05 MM	
Carat Weight	2.01 CARATS
Color Grade	E
Clarity Grade	VS 2
Cut Grade	EXCELLENT
Depth	68%
Table	58%
Tilt	Medium to Slightly Thick (Faceted)
Girdle	
Culet	Pointed
Polish	EXCELLENT
Symmetry	EXCELLENT
Fluorescence	NONE

Comments:
This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.



THIS DOCUMENT WAS PRODUCED WITH THE FOLLOWING SECURITY MEASURES: SPECIAL DOCUMENT PAPER, INK SCREENS, WATERMARK BACKGROUND DESIGN, HOLOGRAM AND OTHER SECURITY FEATURES NOT LISTED AND DO EXCEED DOCUMENT SECURITY INDUSTRY GUIDELINES